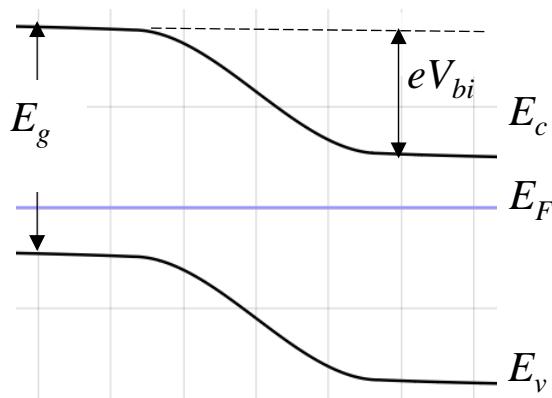
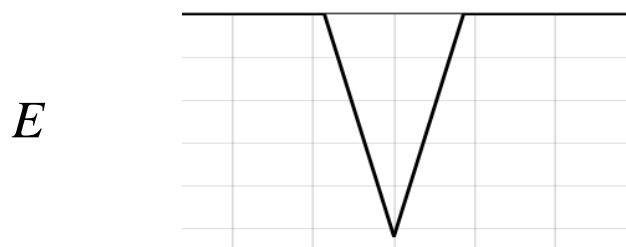
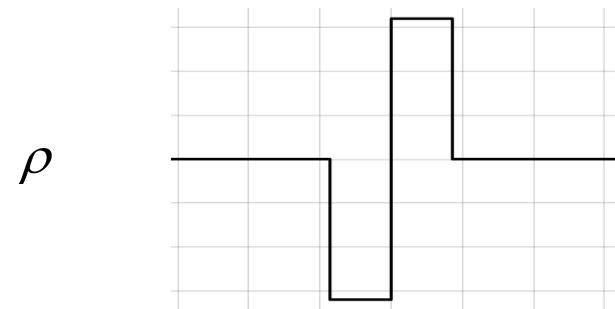


7. pn - Junctions

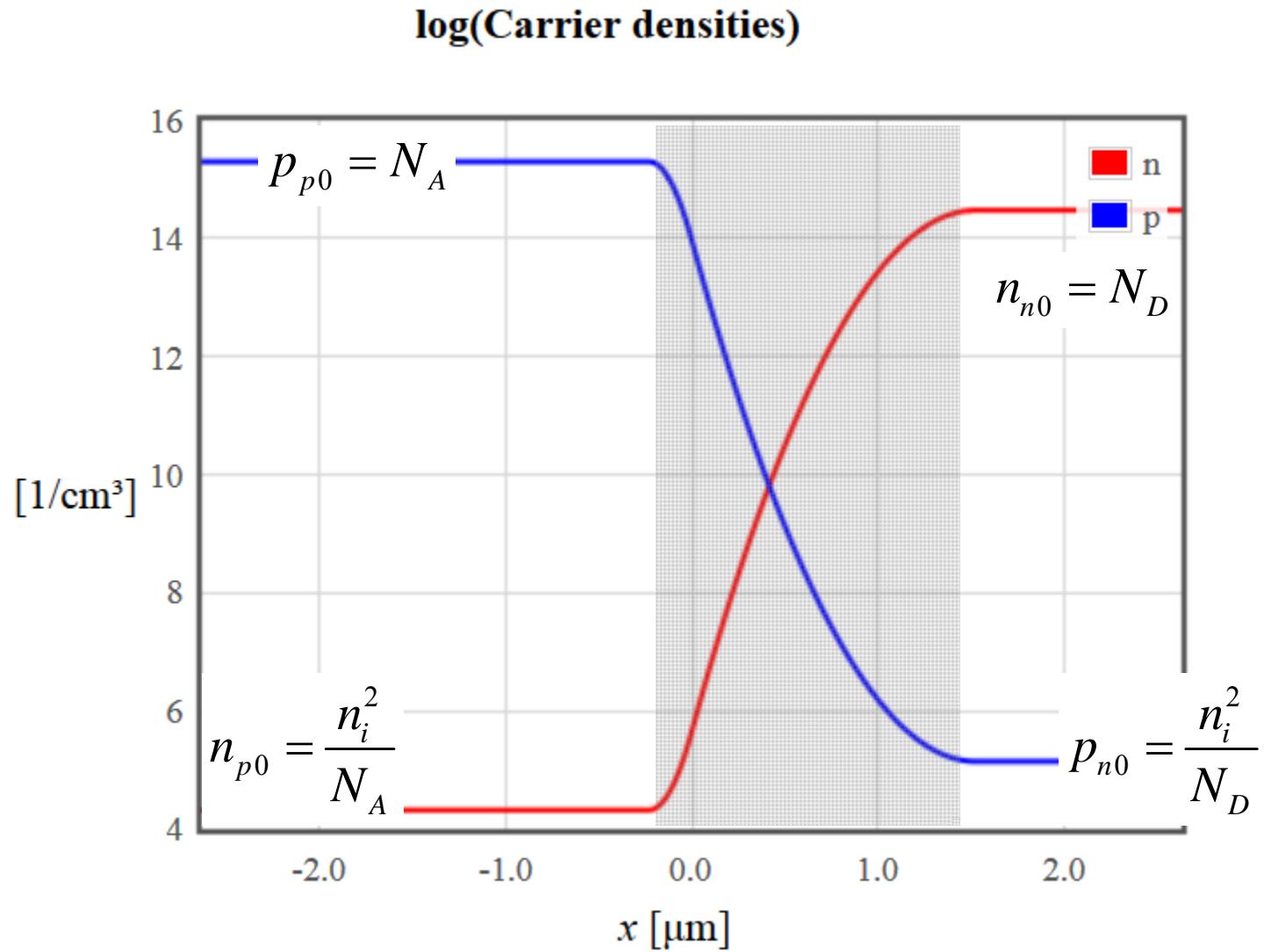
Nov. 13, 2019

abrupt pn junction



$$eV_{bi} = k_B T \ln \left(\frac{N_D N_A}{n_i^2} \right)$$

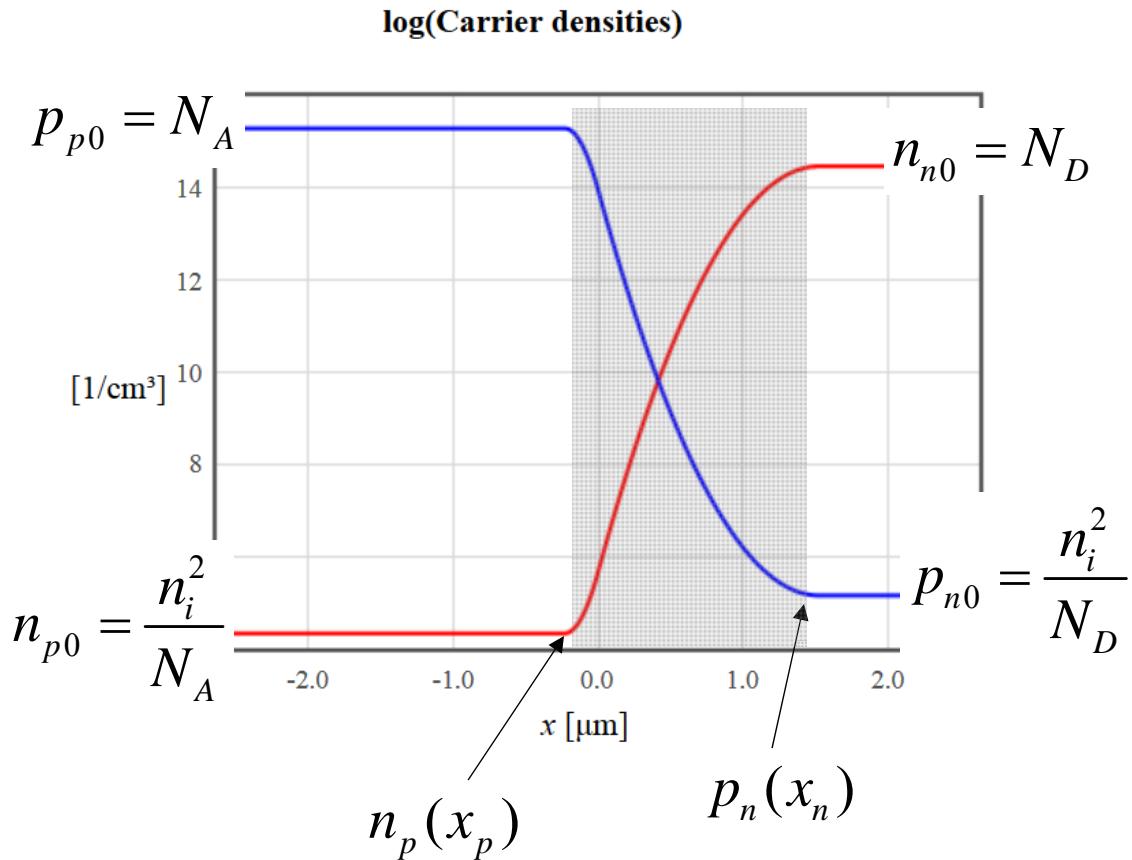
Equilibrium concentrations, $V = 0$



$$n_{p0} p_{p0} = n_{n0} p_{n0} = n_i^2$$

Bias voltage, $V = 0$

$$eV_{bi} = k_B T \ln \left(\frac{N_D N_A}{n_i^2} \right) = k_B T \ln \left(\frac{N_D}{n_{p0}} \right) = k_B T \ln \left(\frac{N_A}{p_{n0}} \right)$$



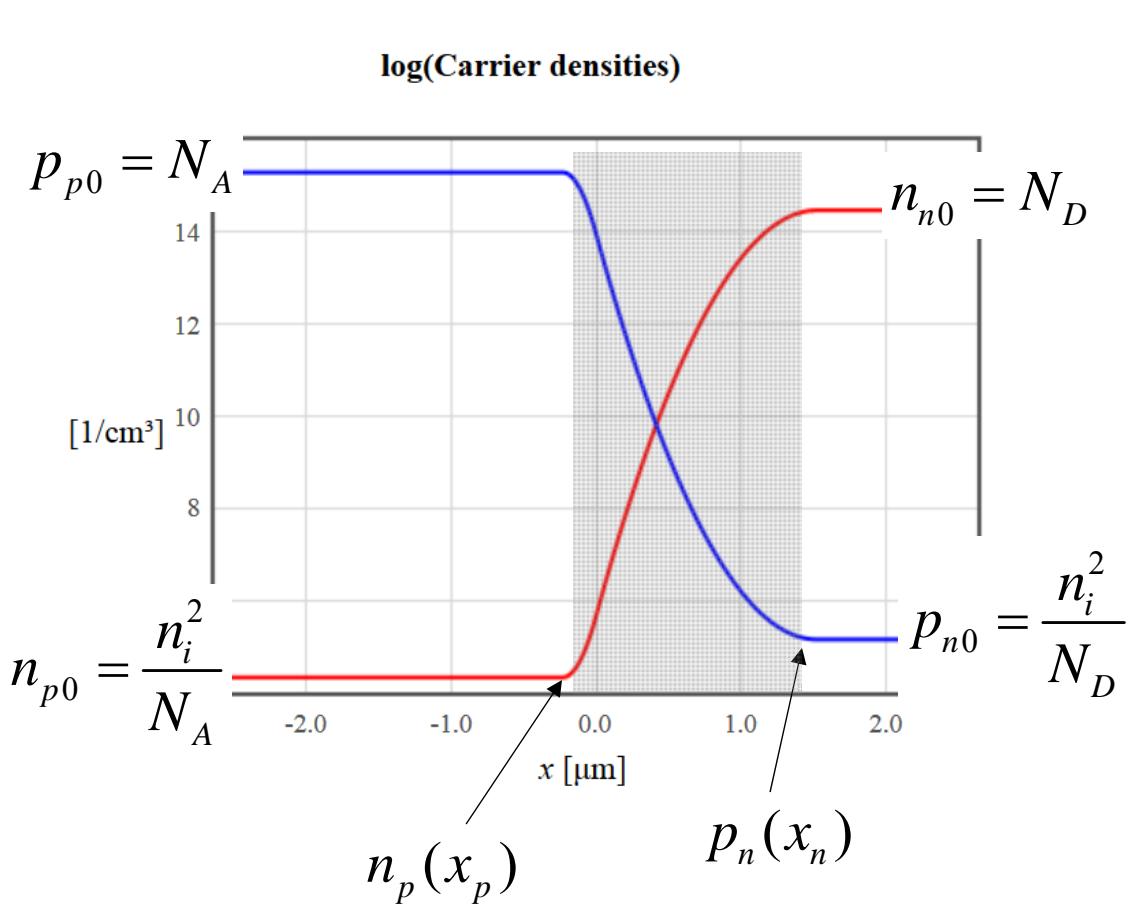
$$n_{p0} p_{p0} = n_{n0} p_{n0} = n_i^2$$

$V = 0$

$n_{p0} = N_D \exp \left(\frac{-eV_{bi}}{k_B T} \right)$
$p_{n0} = N_A \exp \left(\frac{-eV_{bi}}{k_B T} \right)$

Bias voltage, $V \neq 0$

$$eV_{bi} = k_B T \ln \left(\frac{N_D N_A}{n_i^2} \right) = k_B T \ln \left(\frac{N_D}{n_{p0}} \right) = k_B T \ln \left(\frac{N_A}{p_{n0}} \right)$$



$$n_{p0} p_{p0} = n_{n0} p_{n0} = n_i^2$$

$V = 0$

$$n_{p0} = N_D \exp \left(\frac{-eV_{bi}}{k_B T} \right)$$

$$p_{n0} = N_A \exp \left(\frac{-eV_{bi}}{k_B T} \right)$$

$V \neq 0$

$$n_p(x_p) = N_D \exp \left(\frac{-e(V_{bi} - V)}{k_B T} \right)$$

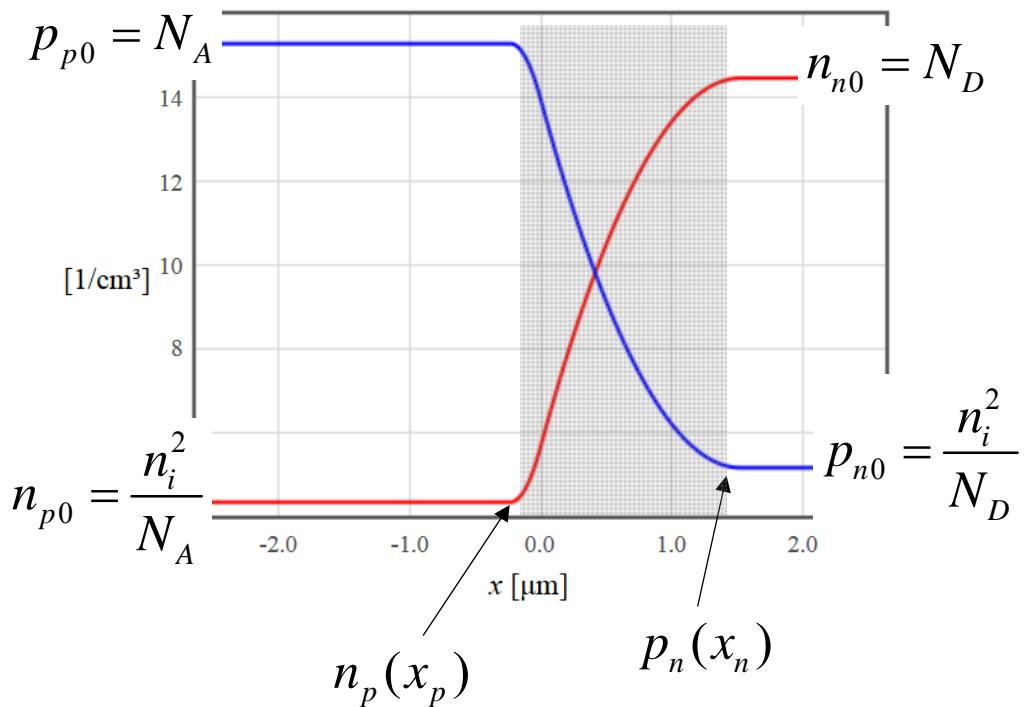
$$p_n(x_n) = N_A \exp \left(\frac{-e(V_{bi} - V)}{k_B T} \right)$$

Bias voltage, $V \neq 0$

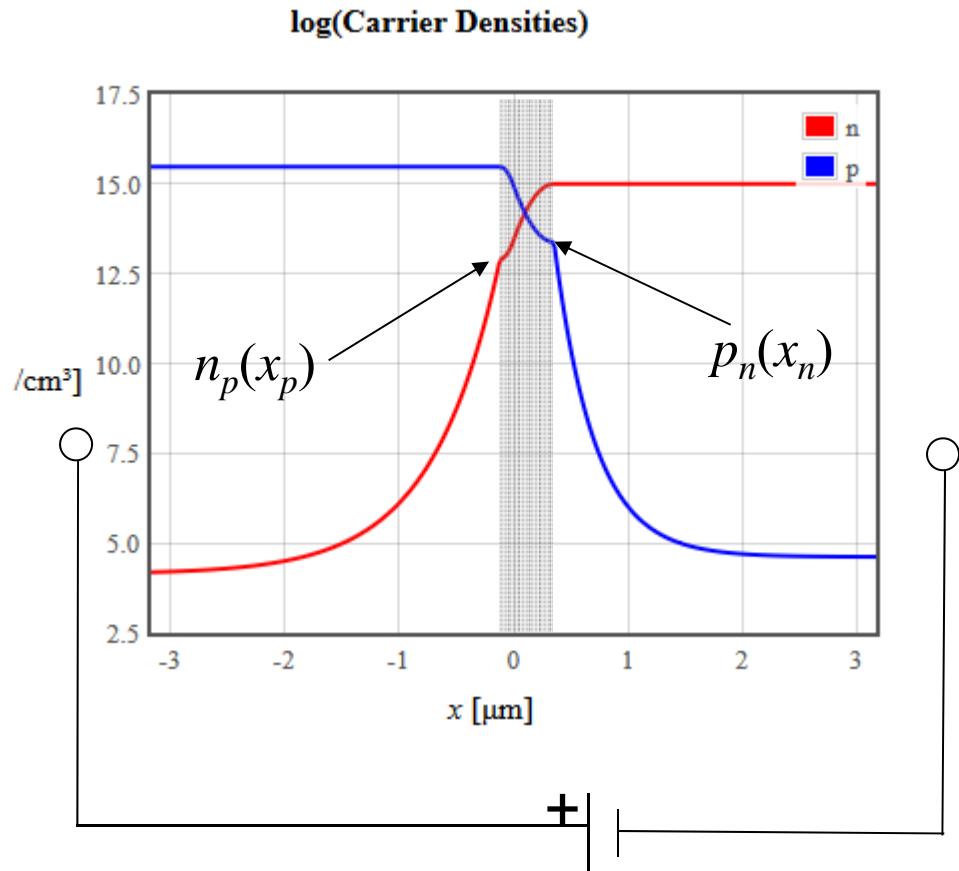
$$n_p(x_p) = N_D \exp\left(\frac{-e(V_{bi} - V)}{k_B T}\right) = n_{p0} \exp\left(\frac{eV}{k_B T}\right)$$

$$p_n(x_n) = N_A \exp\left(\frac{-e(V_{bi} - V)}{k_B T}\right) = p_{n0} \exp\left(\frac{eV}{k_B T}\right)$$

log(Carrier densities)



Forward bias, $V > 0$



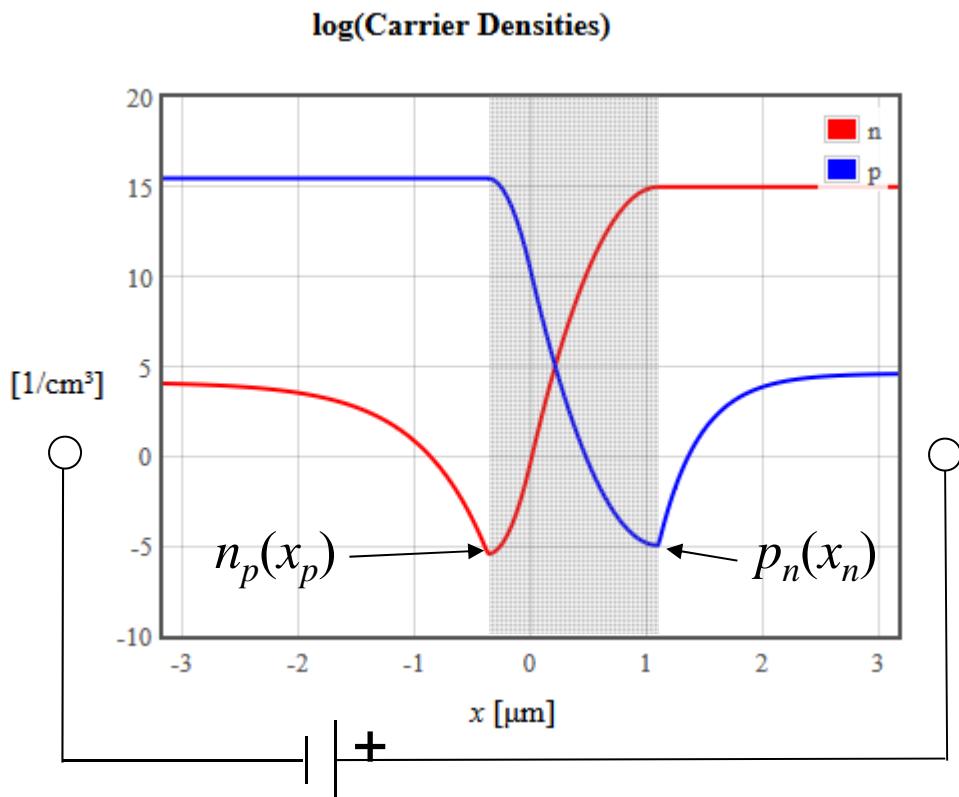
Electrons and holes are driven towards the junction.
The depletion region becomes narrower

$$n_p(x_p) = n_{p0} \exp\left(\frac{eV}{k_B T}\right)$$

$$p_n(x_n) = p_{n0} \exp\left(\frac{eV}{k_B T}\right)$$

Minority electrons are injected into the p-region
Minority holes are injected into the n-region

Reverse bias, $V < 0$



Electrons and holes are driven away from the junction.
The depletion region becomes wider

$$n_p(x_p) = n_{p0} \exp\left(\frac{eV}{k_B T}\right)$$

$$p_n(x_n) = p_{n0} \exp\left(\frac{eV}{k_B T}\right)$$

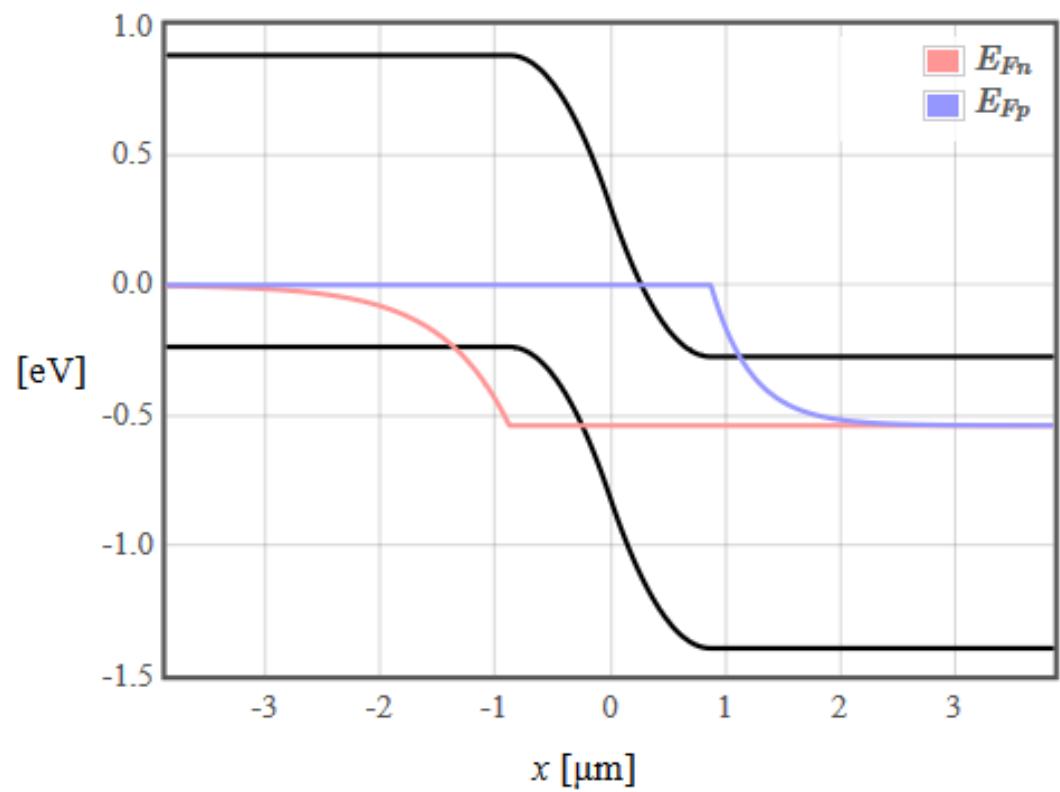
Minority electrons are extracted from the p-region by the electric field
Minority holes are extracted from the n-region by the electric field

Quasi Fermi level

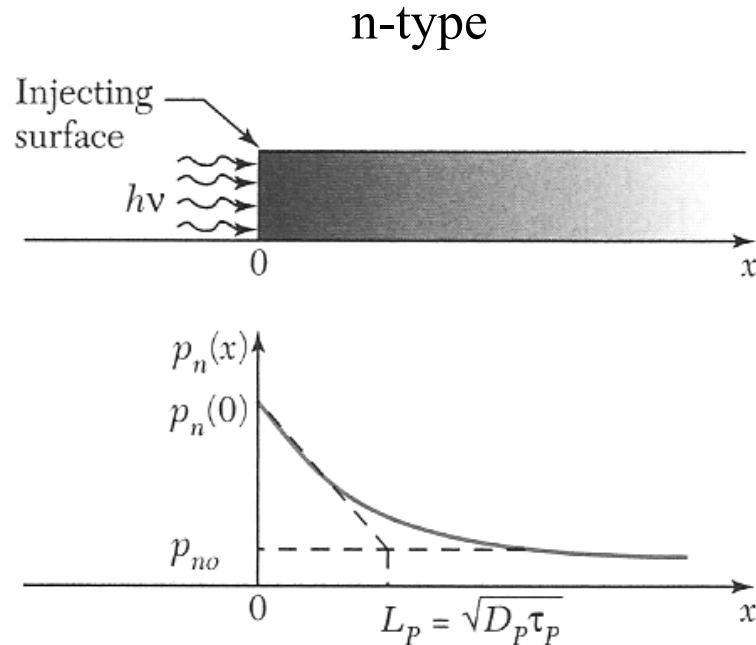
When the charge carriers are not in equilibrium the Fermi energy can be different for electrons and holes.

$$n = N_c \exp\left(\frac{E_{Fn} - E_c}{k_B T}\right)$$

$$p = N_v \exp\left(\frac{E_v - E_{Fp}}{k_B T}\right)$$



Review of Diffusion



$$D_p \frac{\partial^2 p_n}{\partial x^2} = \frac{p_n - p_{n0}}{\tau_p}$$

↑
recombination time

$$p_n(x) = p_{n0} + (p_n(0) - p_{n0}) \exp\left(\frac{-x}{L_p}\right)$$

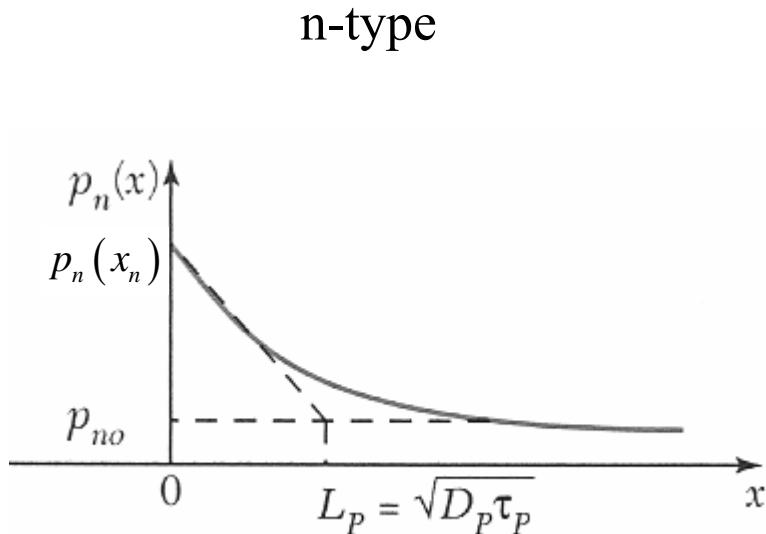
$$L_p = \sqrt{D_p \tau_p}$$

↑

diffusion length

Injection only occurs at the surface. There the minority carrier density is $p_n(0)$.

Diffusion current



$$p_n(x) = p_{n0} + (p_n(x_n) - p_{n0}) \exp\left(\frac{-x}{L_p}\right)$$

$$J_{diff,p} = -eD_p \frac{dp}{dx}$$

$$J_{diff,p} = -eD_p \frac{dp}{dx} = (p_n(x_n) - p_{n0}) \frac{eD_p}{L_p} \exp\left(\frac{-x}{L_p}\right)$$

At the edge of the depletion region:

$$J_{diff,p} = -eD_p \frac{dp}{dx} = (p_n(x_n) - p_{n0}) \frac{eD_p}{L_p}$$

Diffusion current

$$J_{diff,p} = (p_n(x_n) - p_{n0}) \frac{eD_p}{L_p}$$



$$p_n(x_n) = p_{p0} \exp\left(-\frac{e(V_{bi} - V)}{k_B T}\right)$$

$$J_{diff,p} = \left(p_{p0} \exp\left(-\frac{e(V_{bi} - V)}{k_B T}\right) - p_{n0} \right) \frac{eD_p}{L_p}$$



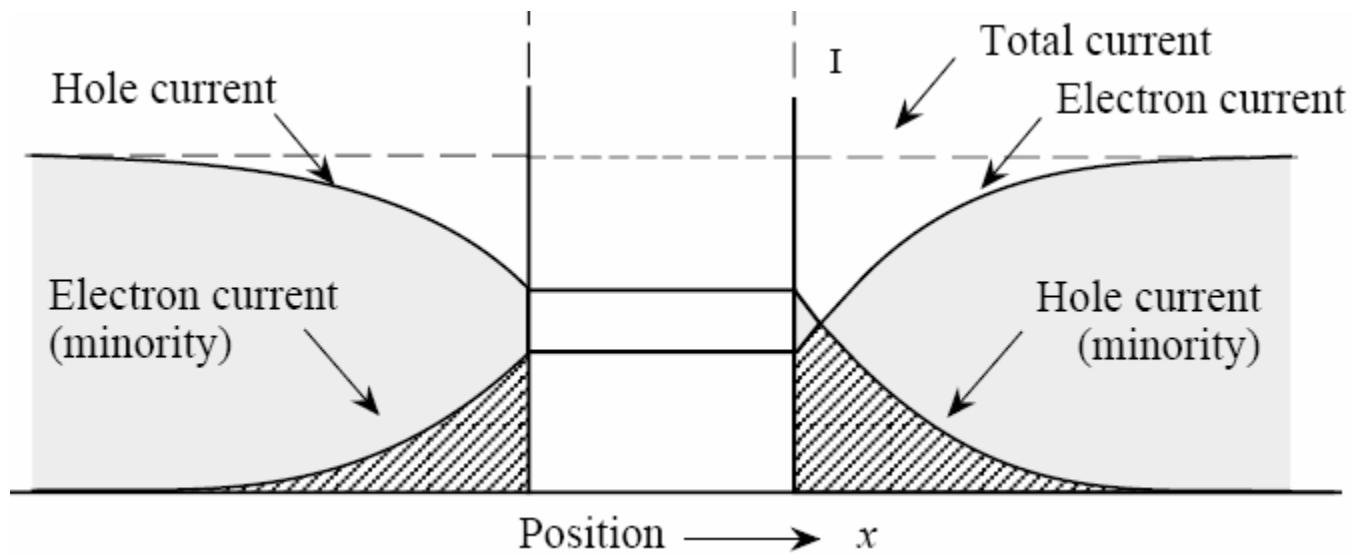
$$p_{p0} = p_{n0} \exp\left(\frac{eV_{bi}}{k_B T}\right)$$

$$J_{diff,p} = p_{n0} \frac{eD_p}{L_p} \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right)$$

Diffusion current

$$J_{diff,p} = \frac{p_{n0}eD_p}{L_p} \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right)$$

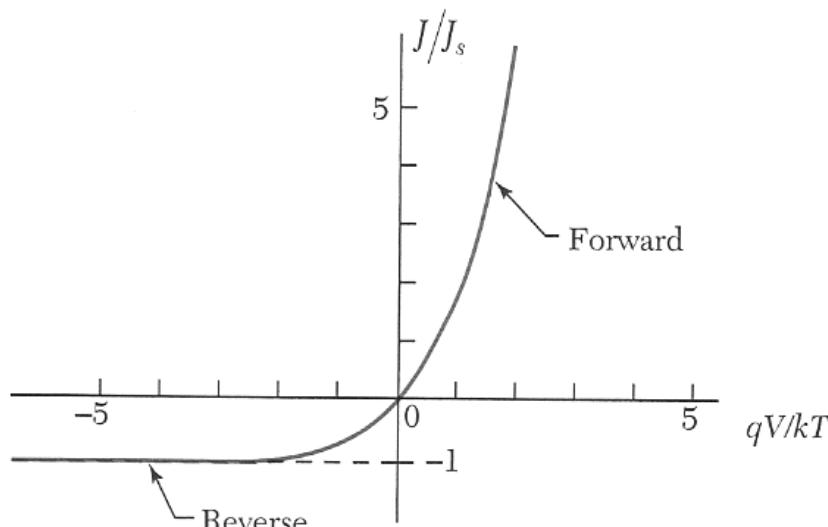
$$J_{diff,n} = \frac{n_{p0}eD_n}{L_n} \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right)$$



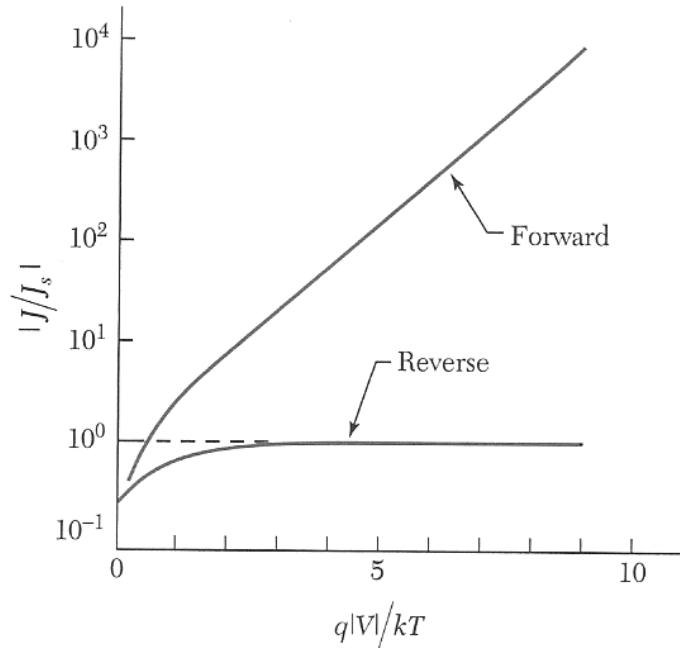
Diode current

$$I = eA \left(\frac{p_{n0}D_p}{L_p} + \frac{n_{p0}D_n}{L_n} \right) \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right) = I_s \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right)$$

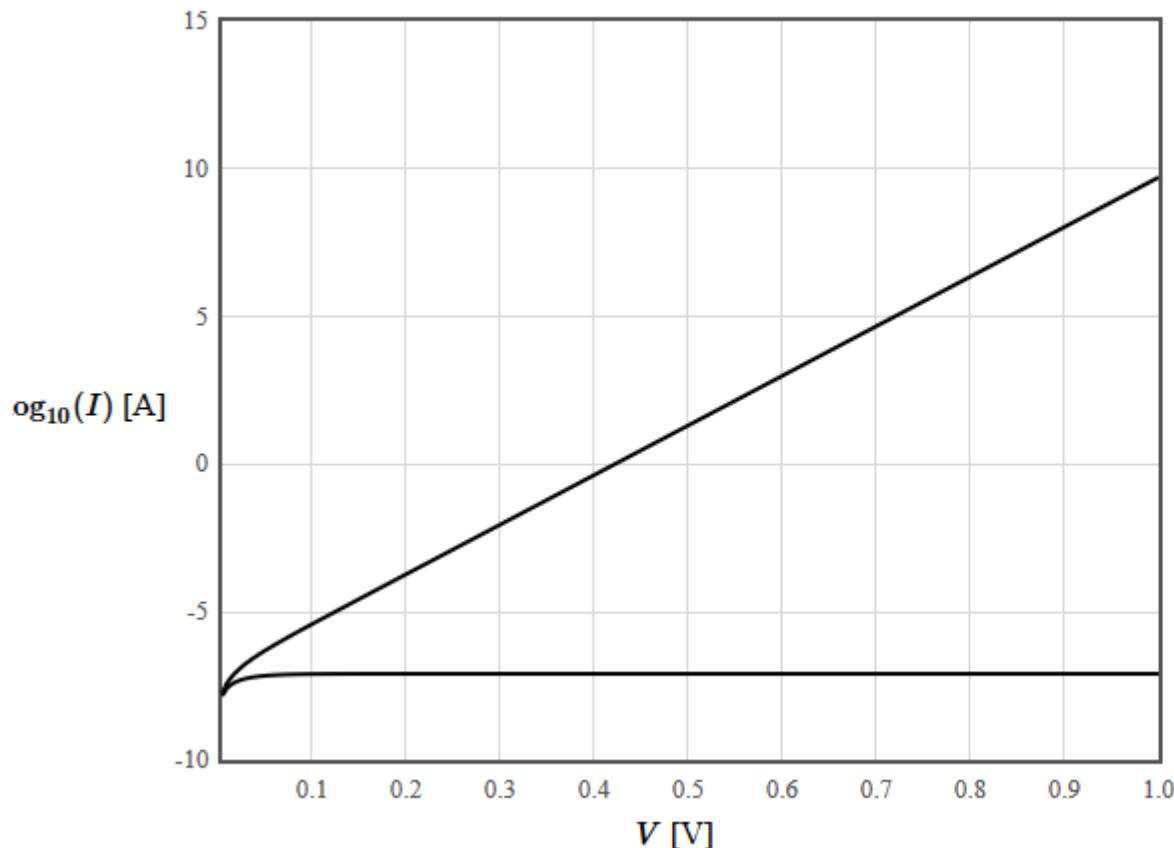
Area



Saturation current



Diode I-V characteristics

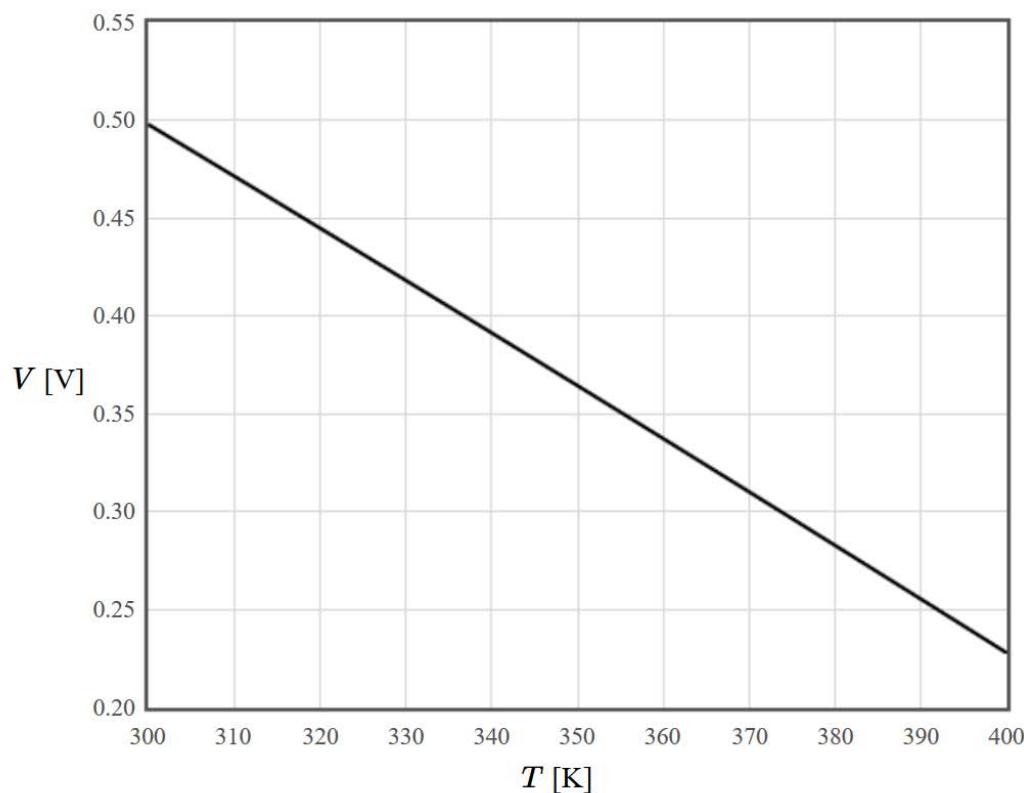


$A = 1E-3$	cm^2	
$N_c(300K) = 1.04E19$	cm^{-3}	
$N_v(300K) = 6.0E18$	cm^{-3}	
$E_g = 0.7437 - 4.77E-4 \cdot T \cdot T / (T + 235) \text{ eV}$		
$\mu_p = 1900$	cm^2/Vs	
$\tau_p = 1E-8$	s	
$N_a = 1E17$	cm^{-3}	
$\mu_n = 3900$	cm^2/Vs	
$\tau_n = 1E-8$	s	
$N_d = 5E17$	cm^{-3}	
$T = 300$	K	
Replot		
Si	Ge	GaAs

Thermometer

$$I_S = A e n_i^2 \left(\frac{D_p}{L_p N_d} + \frac{D_n}{L_n N_a} \right)$$

$$n_i = \sqrt{N_c \left(\frac{T}{300} \right)^{3/2} N_v \left(\frac{T}{300} \right)^{3/2} \exp \left(\frac{-E_g}{2k_B T} \right)}$$
$$D_n = \frac{\mu_n k_B T}{e}$$



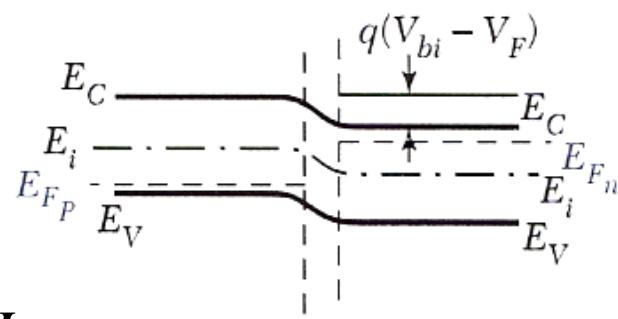
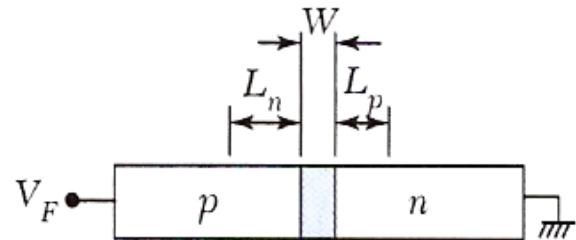
$A = 1\text{E-}3 \text{ cm}^2$
 $N_c(300K) = 2.78\text{E}19 \text{ cm}^{-3}$
 $N_v(300K) = 9.84\text{E}18 \text{ cm}^{-3}$
 $E_g = 1.166 - 4.73\text{E-}4 * T * T / (T + 636) \text{ eV}$

$\mu_p = 480 \text{ cm}^2/\text{Vs}$
 $\tau_p = 1\text{E-}8 \text{ s}$
 $N_a = 1\text{E}17 \text{ cm}^{-3}$

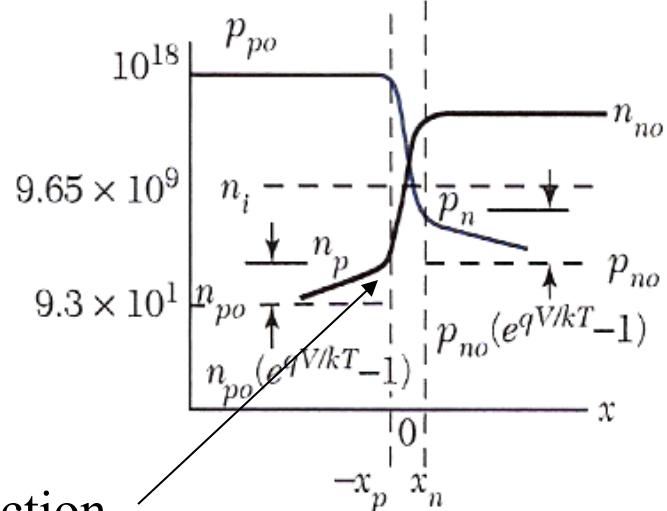
$\mu_n = 1350 \text{ cm}^2/\text{Vs}$
 $\tau_n = 1\text{E-}8 \text{ s}$
 $N_d = 5\text{E}17 \text{ cm}^{-3}$

$T_{start} = 300 \text{ K}$
 $T_{stop} = 400 \text{ K}$
 $I = 1\text{E-}6 \text{ A}$

Forward

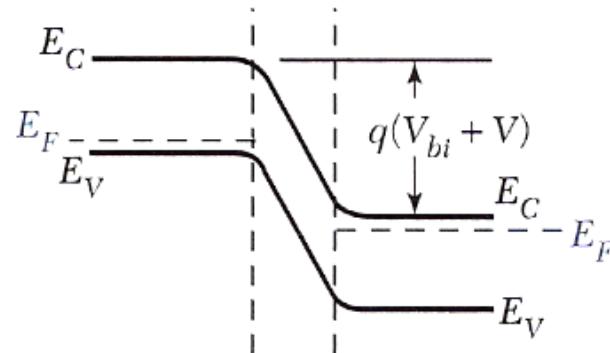
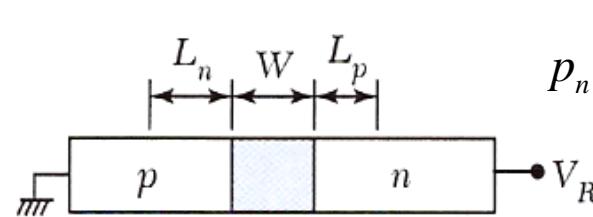


$$J_{diff} > J_{drift}$$

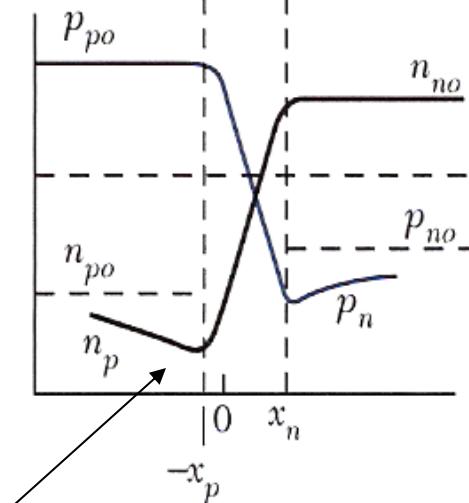


Injection

Reverse



$$J_{diff} < J_{drift}$$

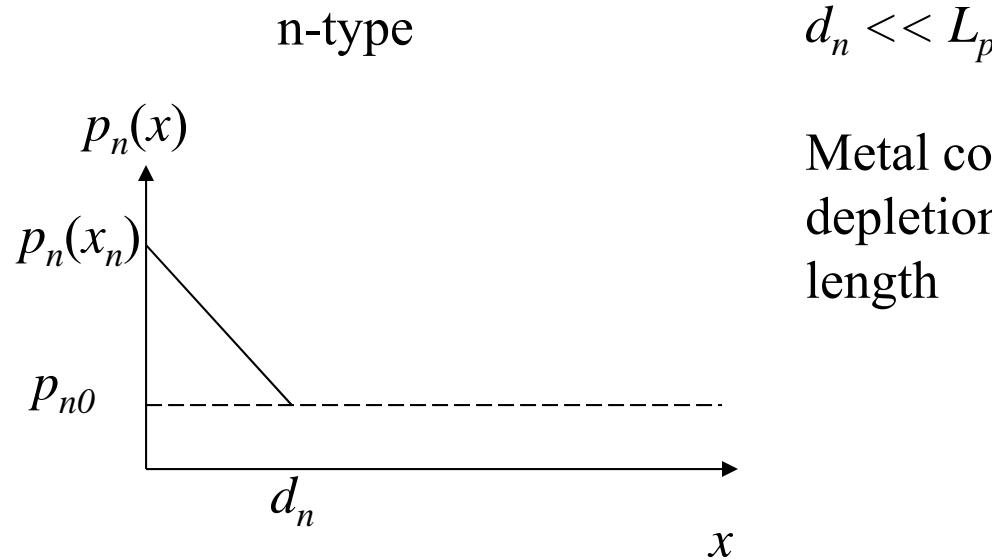


Extraction

$$n_p(x_p) = n_{p0} \exp\left(\frac{eV}{k_B T}\right)$$

$$p_n(x_n) = p_{n0} \exp\left(\frac{eV}{k_B T}\right)$$

Short diode



Metal contact is much closer to the depletion region than the diffusion length

$$J_{diff,p} = -eD_p \frac{dp}{dx}$$

$$J_{diff,p} = -eD_p \frac{dp}{dx} = \frac{eD_p}{d_n} (p_n(x_n) - p_{n0})$$

Diffusion current

$$J_{diff,p} = (p_n(x_n) - p_{n0}) \frac{eD_p}{d_n}$$

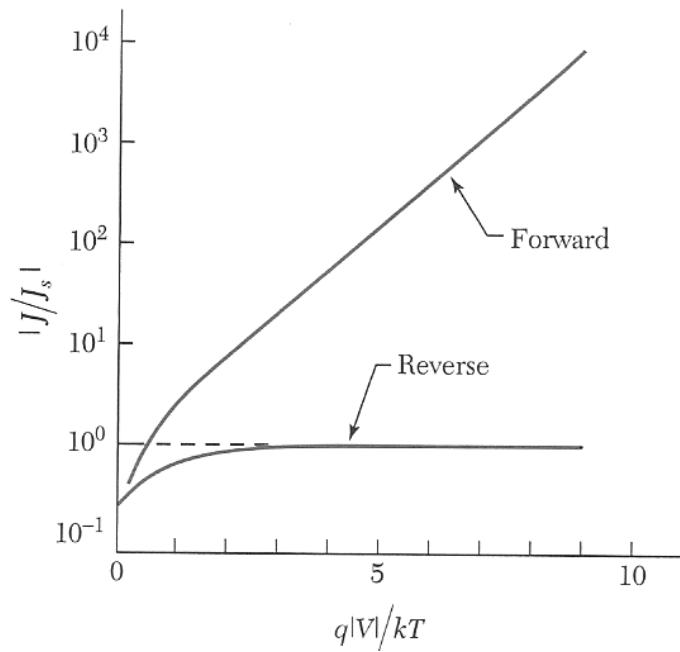
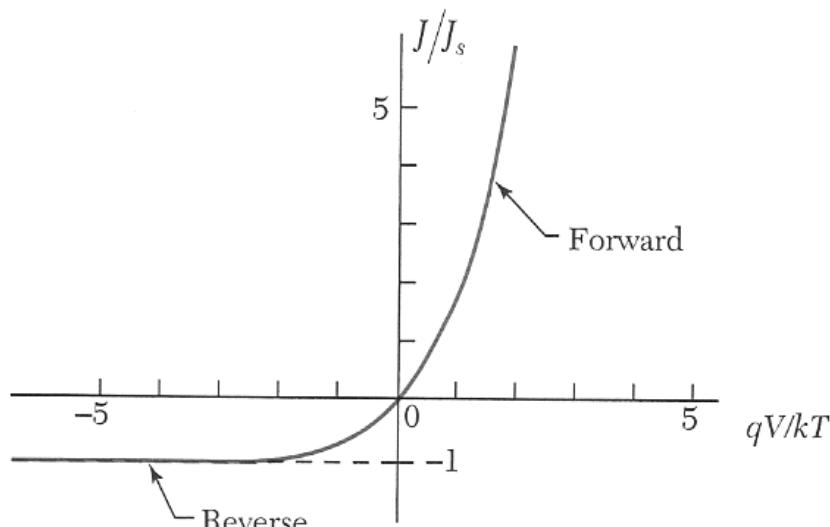
$$J_{diff,p} = \left(p_{n0} \exp\left(\frac{e(V)}{k_B T}\right) - p_{n0} \right) \frac{eD_p}{d_n}$$

$$J_{diff,p} = \frac{p_{n0} e D_p}{d_n} \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right)$$

Short diode current

$$I = eA \left(\frac{p_{n0}D_p}{d_n} + \frac{n_{p0}D_n}{d_p} \right) \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right) = I_s \left(\exp\left(\frac{eV}{k_B T}\right) - 1 \right)$$

Area



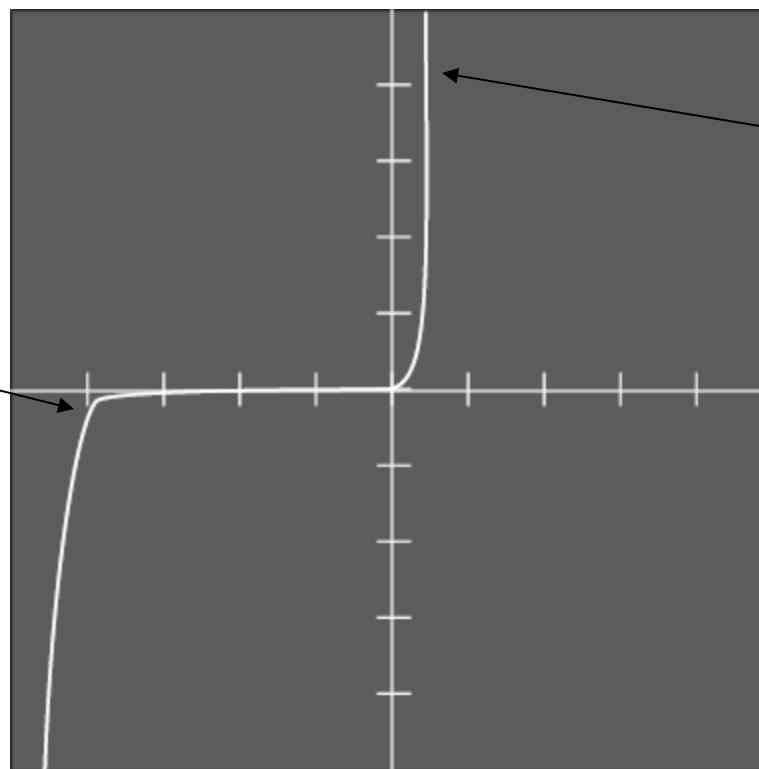
Real diodes

$$I = I_s \left(\exp\left(\frac{eV}{nk_B T}\right) - 1 \right)$$

n = nonideality factor

$n = 1$ for an ideal diode

reverse
breakdown
voltage



series resistance

Real diodes

There is constant generation/recombination of electron hole pairs.

In forward bias there is an extra current from recombination.

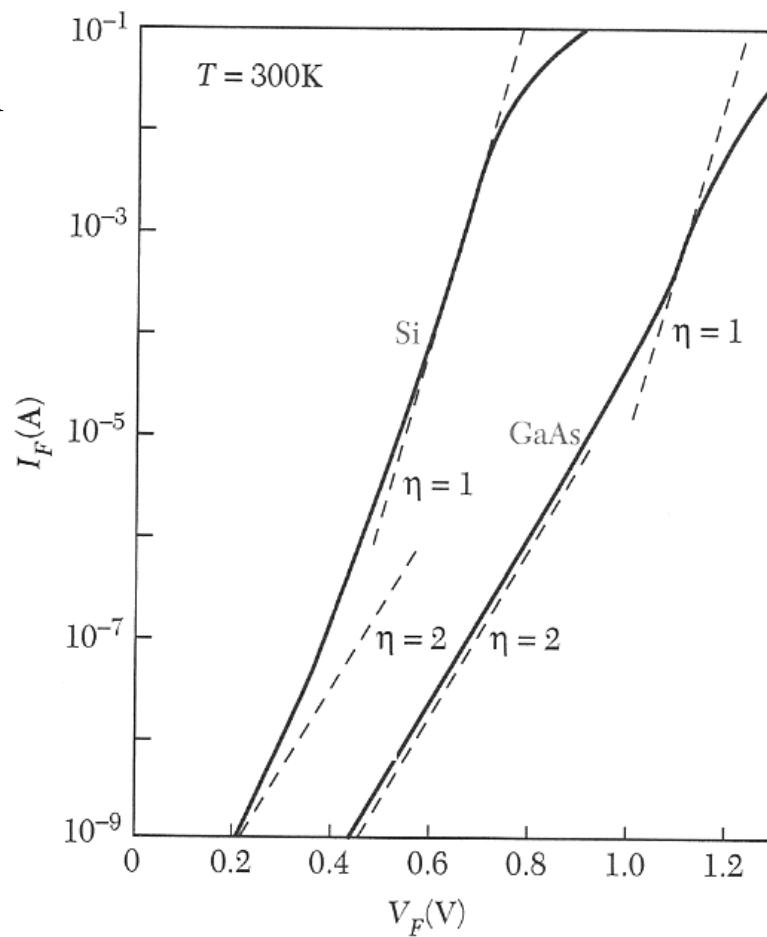
In reverse bias there is an extra current from generation.

Low bias:
recombination
dominates, $n = 2$

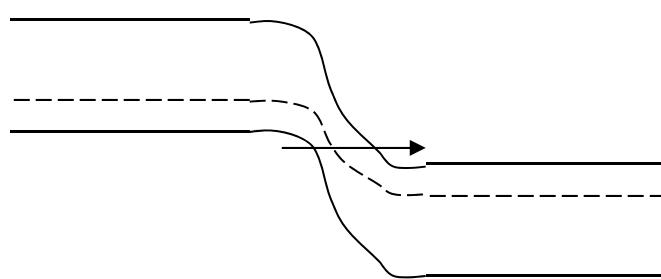
$$I = I_s \left(\exp\left(\frac{eV}{nk_B T}\right) - 1 \right)$$

Very high bias: series resistance

High bias: ideal behavior, $n = 1$



Zener tunneling

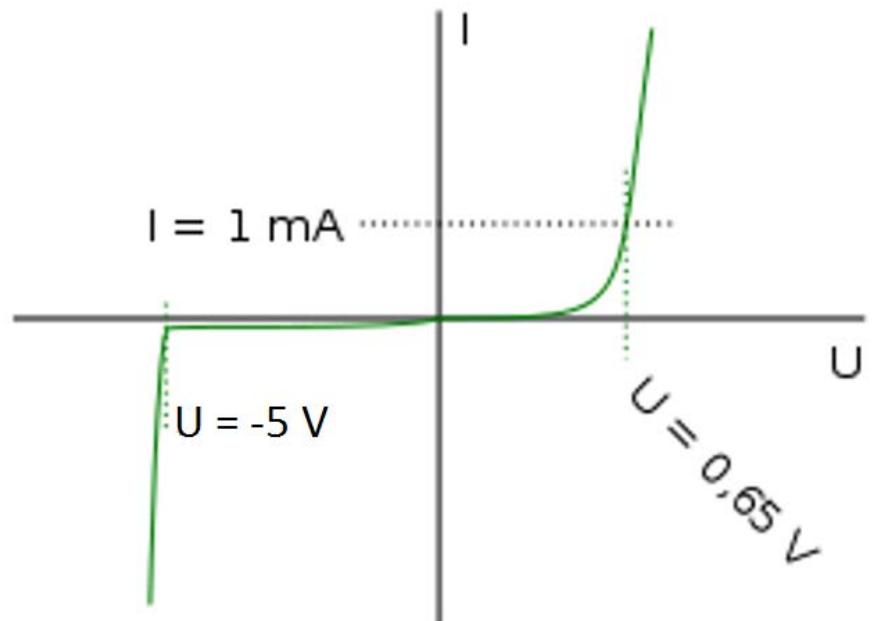


(Zener diode)

Electrons tunnel from valence band to conduction band

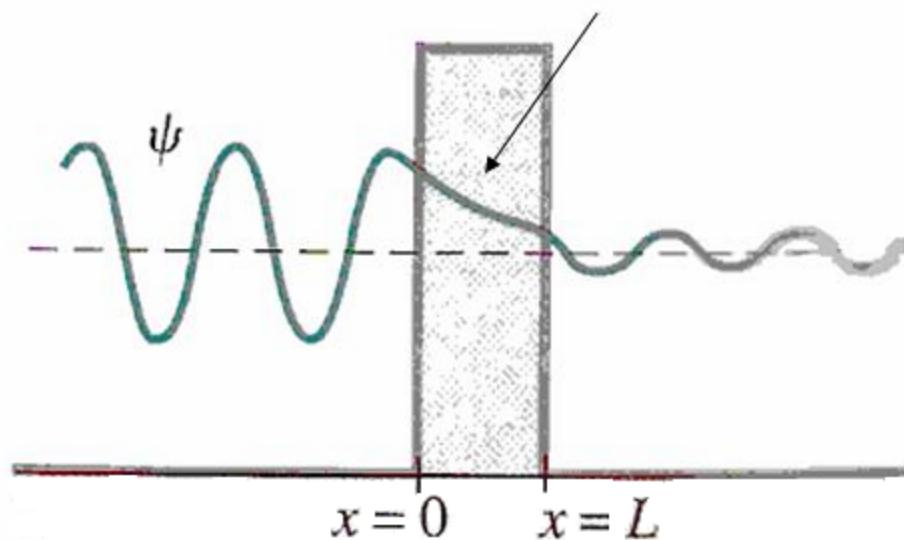
Occurs at high doping

$$|V_{\text{zener}}| < 5.6 \text{ V}$$



Tunneling

wave decays exponentially in the classically forbidden region



Tunneling is a wave phenomena. Tunneling and total internal reflection are used in a beam splitter.

Zener tunneling

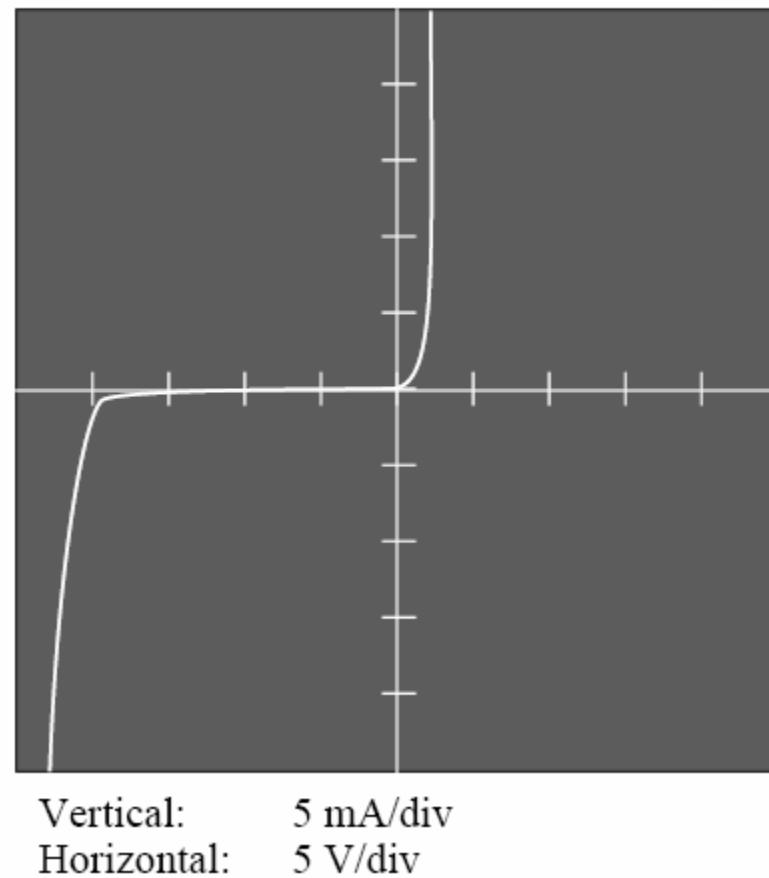
Breakdown voltage is typically much lower than the breakdown voltage of an avalanche diode and can be tuned by adjusting the width of the depletion layer.

Used to provide a reference voltage.

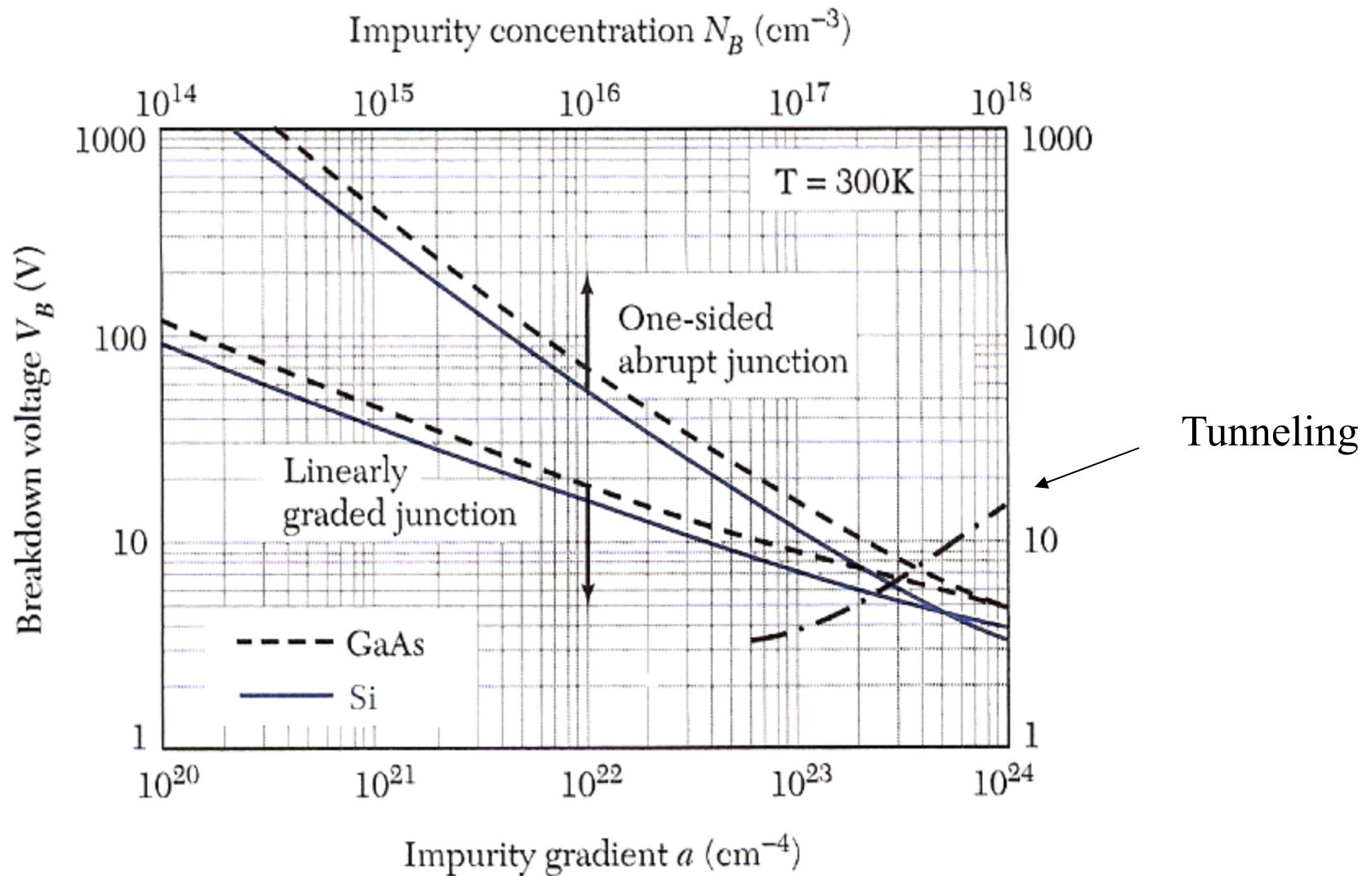
Avalanche breakdown

Impact ionization
causes an avalanche of
current

Occurs at low doping



Avalanche breakdown



metal - semiconductor contacts

- Photoelectric effect
- Schottky barriers
- Schottky diodes
- Ohmic contacts
- Thermionic emission
- Tunnel contacts

